

# Surfaces and Interfaces: *Ab-initio* calculations for the study of material and design of devices

## Pre-Thesis

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21-10-2015

# Materials science

We need novel materials for:

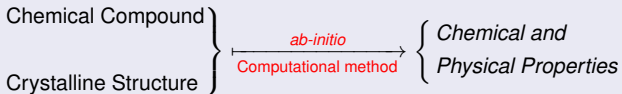
- Energy harvesting, conversion, storage, efficiency
- Environmental protection and reparation
- Health care and biomedical engineering
- Pharmaceuticals (crystallization, stability, polytypes)
- Monitoring safety of foods
- Information and communication technologies
- Fundamental science (graphene and 2D materials, topological insulators, entangled spins for quantum computing, high-T c )
- Experimental science (detectors, sensors, magnets)

# Thesis Intent: Surface and Interface science

## Surfaces and Interfaces between Organic and Inorganic Materials

- Inorganic/Inorganic Interface: Graphene on crystalline (0001) SiO<sub>2</sub>
- Organic/Inorganic Interface: PDIF-CN<sub>2</sub> Organic crystal on crystalline (001) Silicon
- Organic/Organic Interface: PCBM Organic crystal on P3HT Polymer

### *Ab-initio* calculation: what does it mean?



Without the need for empirical *a priori* information  
(even if such information can be useful)

# Theoretical summary (I)

- Electrons and nuclei Hamiltonian

$$H_{tot} = \sum_i \frac{\mathbf{p}_i^2}{2m} + \sum_I \frac{\mathbf{P}_I^2}{2M_I} + \sum_i V_{nucl}(\mathbf{r}_i) + \frac{1}{2} \sum_{i \neq j} \frac{e^2}{|\mathbf{r}_i - \mathbf{r}_j|} + \frac{1}{2} \sum_{I \neq J} \frac{z_I z_J e^2}{|\mathbf{R}_I - \mathbf{R}_J|}$$

$$V_{nucl}(\mathbf{r}) = - \sum_I \frac{z_I e^2}{|\mathbf{r} - \mathbf{R}_I|}$$

## Density Functional Theory (DFT)

- Hohenberg-Kohn Theorem: bijective relation  
Electron charge density ↔ Potential
- Kohn-Sham equations

- $\left[ -\frac{\hbar^2 \nabla^2}{2m} + V_{ext}(\mathbf{r}) + V_H(\mathbf{r}) + V_{xc}(\mathbf{r}) \right] \phi_i(\mathbf{r}) = \epsilon_i \phi_i(\mathbf{r})$
- $V_{xc}(\mathbf{r}) = \frac{\delta E_{xc}[n]}{\delta n(\mathbf{r})}$ .

# Theoretical summary (II)

## Exchange-Correlation functionals

- Local-Density-Approximation (LDA)

$$E_{xc}^{LDA}[n] = \int \epsilon_{xc}(n(\mathbf{r}))n(\mathbf{r})d\mathbf{r}$$

- Generalized Gradient Approximation (GGA)

$$E_{xc}[n(\mathbf{r})] = \int \epsilon_{xc}(n(\mathbf{r}))F_{xc}(n(\mathbf{r}), |\nabla n(\mathbf{r})|)n(\mathbf{r})d\mathbf{r}$$

## Hellmann-Feynman Theorem and the geometrical optimization problem

- $H(\lambda) \rightarrow H_e(\mathbf{r}; \mathbf{R})$

- $H_e(\lambda)\psi_n(\mathbf{r}; \mathbf{R}) = E_n(\lambda)\psi_n(\mathbf{r}; \mathbf{R})$

- $\langle \psi_m(\mathbf{r}; \lambda) | \frac{\partial H(\lambda)}{\partial \lambda_i} | \psi_m(\mathbf{r}; \lambda) \rangle = \frac{\partial E_m}{\partial \lambda_i}$

# Theoretical summary (III): long range interaction

## GRIMME -Van der Waals interaction

$$E_{KS-vdW} = E_{KS} + s_6 \frac{1}{2} \sum_{i \neq j} \frac{C_6^{ij}}{R_{ij}^6} f_{dmp}(R_{ij})$$

$$f_{dmp}(R_{ij}) = \frac{1}{1 + \exp(-d(\frac{R_{ij}}{R_r} - 1))} \quad R_{ij} = |R_i - R_j|$$

Each pair contributes a  $R_{ij}^{-6}$ ,  $f_{dmp}$  is a dumping function that works as a cutoff,  $R_r$  is the vdW radii for the two ions,  $s_6$ ,  $C_6^{ij}$ ,  $d$  come from experimental data

## Hybrids

Combine orbital dependent HF exchange energy with explicit DF  $E_{xc}$

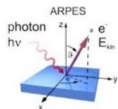
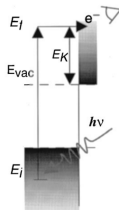
Examples: B3LYP, HSEsol

- 1 Heavier calculation
- 2 Better approximation of some properties (GAP)

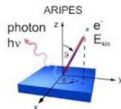
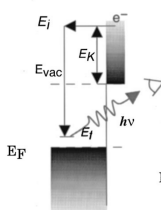
# Excited States and Excitons

DFT is a Ground State Theory → NOT excited states  
 We need more → Many body perturbation theory (MBPT)

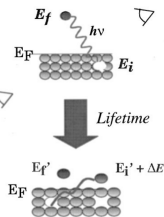
**Direct photoemission**



**Inverse photoemission**



**Absorption**



From quasiparticle corrections to e-h interaction:  
**Excitons**

Andrea Ferretti -  
 Losanna 2015 -  
 Yambo2015 Hands-on

# Codes Used

## Quantum ESPRESSO (QE)

- Basis set: Plane Waves (PW)

## CRYSTAL14

- Linear Combination of Atomic Orbitals (LCAO) approximation → Basis Set: Gaussians

## WAN-T (WANnier- Transport)

- Basis Set: Localised Wannier functions
- Landauer's approach:  $T(E) = \text{Tr}(\Gamma_L G^r \Gamma_R G^a)$
- $I(V) = \frac{2e}{h} \int T(E)[f(E - \mu_L) - f(E - \mu_R)]dE$

## YAMBO

- Basis Set: PW
- Many Body Perturbation Theory (MBPT)
- Optical Properties, Excitons, Bethe-Salpeter



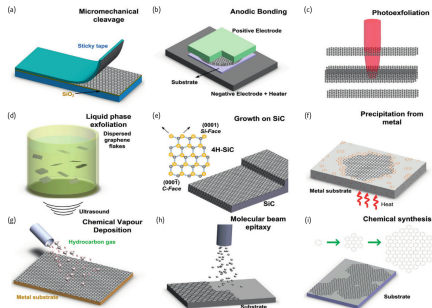


# Graphene on SiO<sub>2</sub>

# Production and processing

## Mass production: scalable processes

- Micromechanical cleavage
- Liquid phase exfoliation
- Thermal exfoliation
- Chemical Vapour Deposition (CVD)
- Synthesis on SiC



**Figure** : F. Bonaccorso et. al., *Materials Today* **15**, 564 (2012) "Production and processing of graphene and 2d crystals"

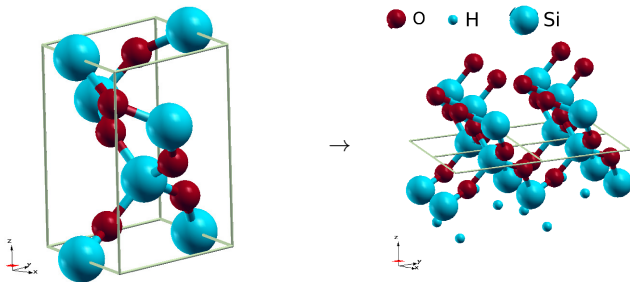
# Graphene/SiO<sub>2</sub>

## Why Graphene/SiO<sub>2</sub> interface?

- Different attempts to synthesize Graphene call for accurate theoretical investigation.
- It is essential to understand and control at the nanoscale its interaction with the supporting substrates.
- SiO<sub>2</sub> is one of the most important and common substrate for application in electronic.

# SiO<sub>2</sub>: 3D→2D

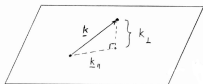
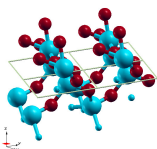
$\alpha$ -quartz SiO<sub>2</sub> Bulk Crystal:  $a=4.913 \text{ \AA}$ ,  $c=5.405 \text{ \AA}$   
Slabcut (0001) O-terminated Surface



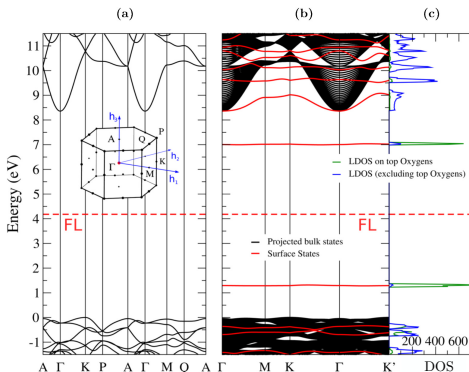
# Geometrical relaxation with fixed cell parameters

The Total Energy minimization checks:

$\Delta E < 10^{-7}$  u.a., RMS of the gradient  $< 0.0003$  a.u, RMS of the displacement  $< 0.0012$  a.u.

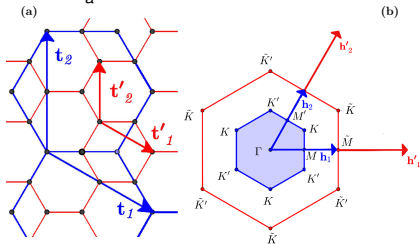


$k_{\parallel}$ : component of  $\mathbf{k}$  parallel to the surface;  $k_{\perp}$ : component of  $\mathbf{k}$  orthogonal to the surface

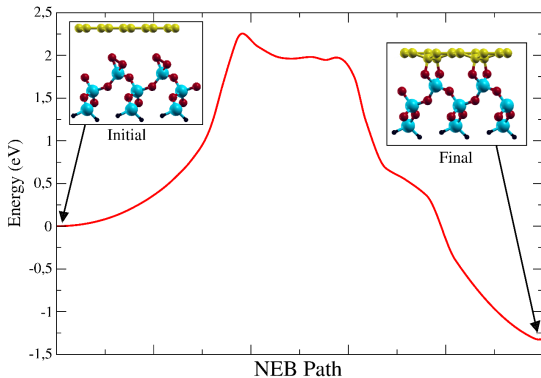


# Graphene

$a=4.913\text{\AA}$ ,  $a'=2.464\text{\AA}$  ( $\frac{2a'-a}{a} \simeq 0.3\%$   $\rightarrow$  for the calculations  $a=4.92\text{\AA}$ ,  $a'=2.46\text{\AA}$ )



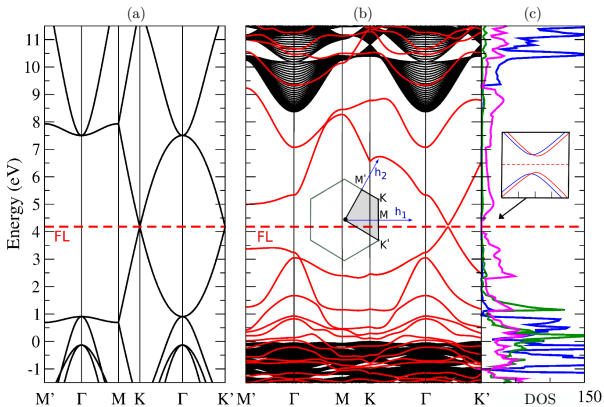
# Graphene/SiO<sub>2</sub>: Geometrical Relaxation (fixed cell parameter)



NOTE: About Covalent Bonds, depassivation of Hydrogen and UHV STM Y. Xu et al Nano Lett. 11,2735(2011), J.C. Koepke APL 107 071603(2015)

# Graphene/SiO<sub>2</sub> bands structure

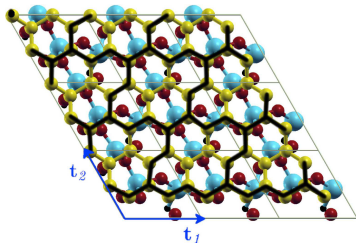
- Left: Graphene 2x2 cell
- Right: Graphene/SiO<sub>2</sub> relaxed with projected DOS Graphene/SiO<sub>2</sub>



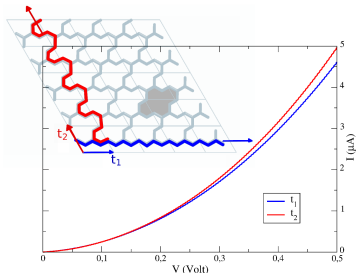
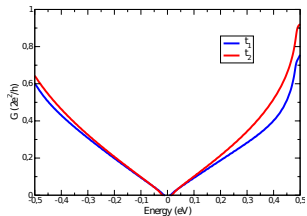


# Asymmetry in Conductance and electrons current

Landauer's approach:  $T(E) = \text{Tr}(\Gamma_L G^r \Gamma_R G^a)$   
 $I(V) = \frac{2e}{h} \int T(E)[f(E - \mu_L) - f(E - \mu_R)]dE$



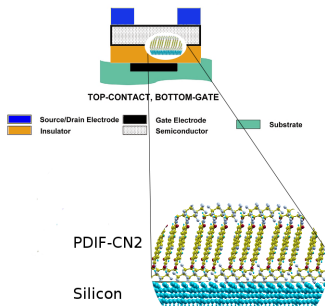
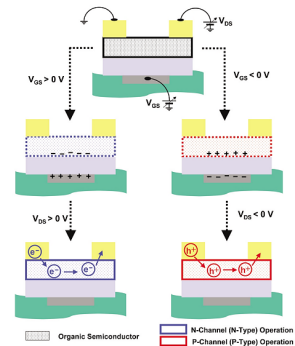
- Graphene/SiO<sub>2</sub> → corrugation: C-O covalent bonds
- Band gap opening, Band Profile modulation
- Modification of  $\pi - \pi$  carbon conjugation: preferred directions for conduction



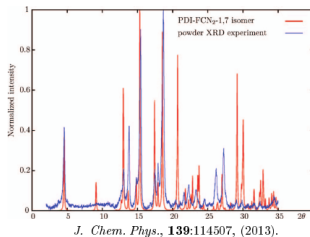
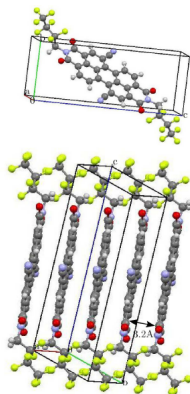
# PDIF-CN<sub>2</sub>/Silicon

# Introduction

- Organic Materials in electronic devices: OFET, OLED, OPV
- n*-type OFET → PDIF-CN<sub>2</sub>



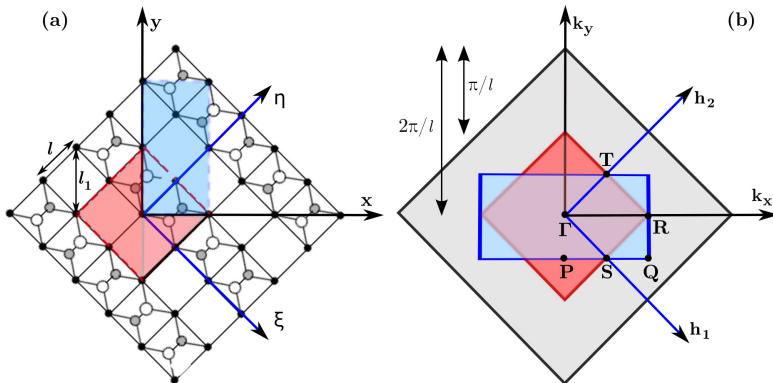
# PDFI-CN<sub>2</sub> crystal Structure



- XRD on crystal powder + *ab-initio* calculation  
→ Geometrical structure
- $\pi - \pi$  stacking  $d = 3.2\text{\AA}$
- triclinic cell:  $a = 5.135\text{\AA}$ ,  $b = 7.385\text{\AA}$ ,  
 $c = 19.598\text{\AA}$ ,  $\alpha = 92.35$  deg,  $\beta = 82.22$  deg,  
 $\gamma = 93.25$  deg.

# Surface Silicon reconstructed and Simulation Cell (I)

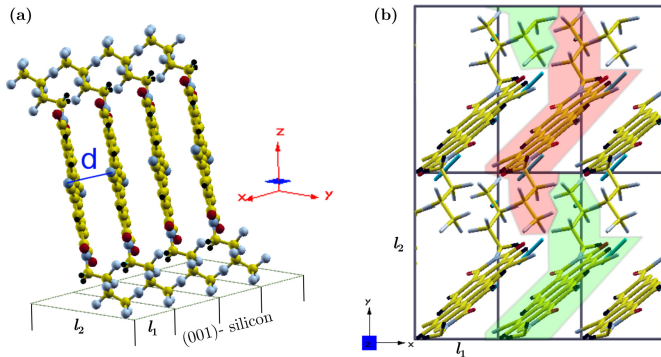
(001) Silicon surface unit-cell lattice parameter  $l=3.83\text{\AA}$



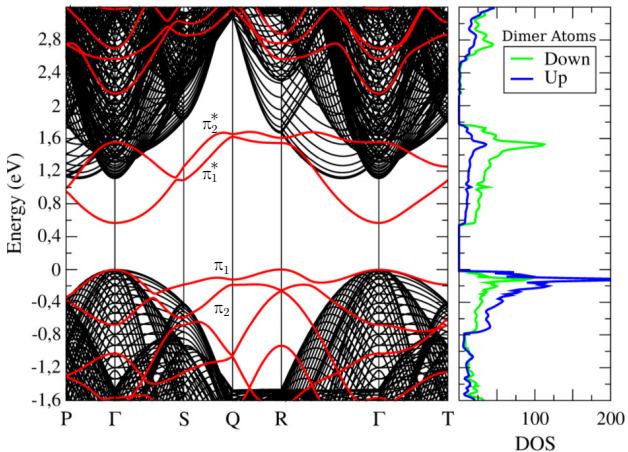
a) Direct lattice and Dimer structure; b) Corresponding Brillouin zones

# Surface Silicon reconstructed and Simulation Cell (2)

The distance between adjacent perylene planes  $d = 3.4\text{\AA}$

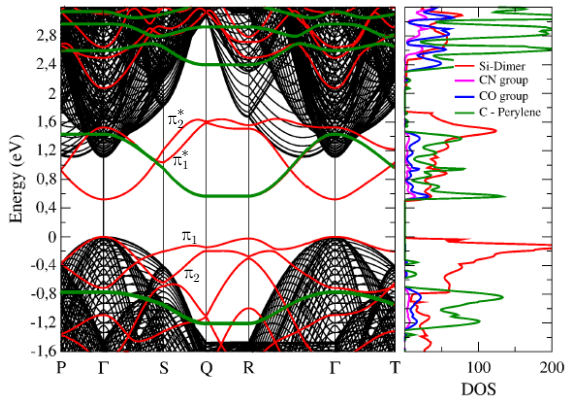
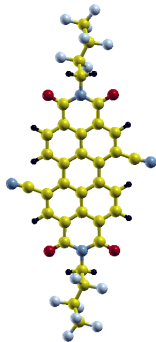


Side (a) and top (b) view of the side-on arrangement; PDIF-CN<sub>2</sub>(66 atoms)+4 Silicon Layers (16 atoms)+ 1 Hydrogen Layer(4 atoms)



DFT electronic band structure and projected density of states of Relaxed  $p(2 \times 2)$  reconstructed Si surface

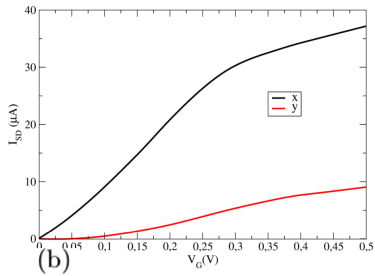
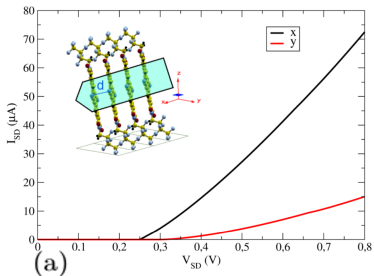
## Modeling the interface



DFT electronic band structure and projected density of states of PDIF-CN<sub>2</sub> on the relaxed  $p(2 \times 2)$  reconstructed Si surface.



## Modeling the interface



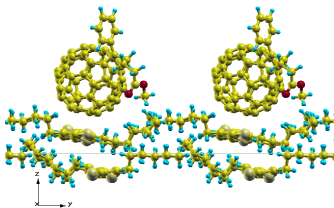
(a) Output plots for the  $I_{SD}$ - $V_{SD}$  characteristics at zero gate voltage  $V_G=0V$ , and (b) transfer plots of  $I_{SD}$  at different biases, in linear regime ( $V_{SD} = 0.25V$ ), for PDIF-CN<sub>2</sub> on Si. The black (red) line corresponds to current flowing along the x (y) directions. In the inset is reported schematically the network of  $\pi$ -conjugated perilene planes which are stacked along the x direction.

# Work in progress

# Organic Photovoltaic cell: PCBM on P3HT

## Work Done:

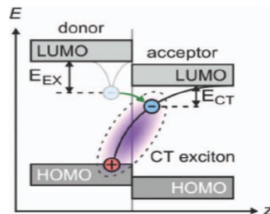
Geometrical structure and Band Structure



Relaxed geometry of a PCBM molecule over 2x1 cell of P3HT: 288 atoms per cell, 794 electrons.

## Work in progress:

Optical Properties and excitons



A schematic diagram depicting the dissociation of an exciton to form a charge transfer exciton across a donor-acceptor interface.  $E_{ex}$  is the single exciton binding energy and  $E_{CT}$  is the charge transfer exciton binding energy.